

Photometrical measuring device

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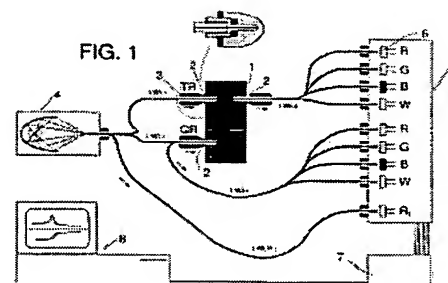
Cited documents:

DE2231873
FR2453399
WO8809494

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Abstract of EP0472899

The measuring device is used to determine the light intensity reaching a detector from a light source as a function of a sample. For this purpose, a flow-type cell (1) for the sample is introduced into an optical waveguide connection (OWG) between a light source (4) and a light detector (5). The optical waveguide (OWG) or waveguides project directly into the cell via openings (2).



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